HICUM

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A Geometry Scalable Physics-Based Compact Bipolar

Transistor model

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List of often used symbols and abbreviations

A_{E0} , L_{E0} emitter window area and perimeter

A_E , L_E effective (electrical) emitter area and perimeter

b_{E0} , l_{E0} emitter window width and length

b_E , l_E effective (electrical) emitter width and length (for definition see [24, 40])

γ_C ratio of periphery to area specific collector current; equal to emitter width increase due to periphery injection, e.g. $b_E = b_{E0} + 2\gamma_C$

I_T , i_T DC and time dependent transfer current of the vertical npn transistor structure

I_{CK} critical current (indicating onset of high-current effects)

μ_n, μ_p electron (hole) mobility

N_{Ci} (average) collector doping under emitter

N_{Cx} collector doping under external base

Q_p hole charge

τ_f forward transit time

w_B , w_{B0} neutral/metallurgical base width

w_{Ci} (effective) collector width under emitter

w_{Cx} (effective) collector width under external base

w_i width of collector injection zone (for charge storage calculation in collector region)

GICCR   Generalized Integral Charge-Control Relation [36]

TRADICA   TRAnsistor DImensioning and CAlculation program [44]

1 Introduction

1.1 Preliminary remarks

The purpose of the following remarks is to provide (i) a motivation behind the compact modeling approach pursued with HICUM, (ii) an overview on its targeted application area, and (iii) a list of requirements for a compact model from different point of views.

Bipolar technology has recently seen a tremendous growth, fuelled mostly by applications that require high speed and driving power on one hand and low noise and distortion on the other hand. Presently, major applications of bipolar technology are:

- Wireless communications in the 0.9 to 5.6 GHz range for, e.g. GSM, Bluetooth, DECT, in the 4-12 GHz range for, e.g. satellite TV, WLAN, and in the 20 to 60GHz range for short range communications, with the first application dominating.
- Fiber-optic communications in the 10 to 60 Gb/s range for, e.g. fast internet access and data transfer (LAN, WAN) as well as TV/HDTV (FTTC, FTTH); production and related design has started for systems up to 10Gb/s, seeing a significant push also for higher integration, such as cross-point switches in BiCMOS processes with emphasis on low-power high-speed bipolar circuits.
- "Linear analog" circuits for, e.g. disc drives, consumer electronics in general, power and auto-motive electronics. Many of these components require reliable and well-established processes with higher breakdown voltages rather than advanced high-speed bipolar processes.
- Fast data acquisition and conversion (ADCs) for, e.g., instrumentation and measurement equip-ment.
- Advanced automotive components at very high frequencies in the range of 24 to 100 GHz for, e.g. collision warning and avoidance. The respective circuits so far have been realized mostly with III-V processes, such as HBTs.

The above sequence is assumed to be roughly in the order of present importance from a business point of view; exact breakdowns are difficult to find, and the ranking can change quickly in areas of rapid growth. The first two applications are perceived to comprise the largest number of designs. As a consequence, compact bipolar transistor modeling should focus on these areas which, fortu-nately, include most of the critical issues of the other applications.

Compact modeling is also strongly connected to development and deployment of process tech-nologies. A physics-based compact model together with the related parameter extraction and gen-eration methodology can contribute significantly to improve the alignment of process development with product design requirements by enabling quick evaluations of the impact of process changes

on device and circuit performance. Compact modeling basically provides a link between process-ing and design.

In general, bipolar processes span over quite a variation in device structure as well as device type. It is recommended to split compact bipolar models into at least two categories:

- vertical devices including high-speed npn and pnp transistors
- lateral devices, mostly pnp transistors.

HICUM is targeted towards the first category. It might be necessary though to divide the first cat-egory again into "low-power" ($BV_{CEO} < 10V$) and "high-power" ($BV_{CEO} > 10V$) transistors if the difference in device design and the electrical application range turns out to be too large for a single model. So far, HICUM has been verified to be accurate for transistors with BV_{CEO} values up to about 15V, but there is no reason why the model should not work for higher voltages.

From the above, the following requirements for a compact model can be derived from an indus-trial point of view:

- high accuracy over a wide electrical (and temperature) range;
- laterally scalable parameter calculation, including variable contact configurations, in order to allow circuit optimization;
- numerical stability and fast execution time, although this is somewhat dependent on the appli-cation.
- physics-based formulation, allowing predictive and statistical modeling;
- reliable and well-defined extraction procedure should be available together with test structures; also, the use of standard equipment and set-ups are only important for, e.g., fast throughput.
- modular formulation of the model equations, minimizing interrelations between different elec-trical regions and facilitating simple implementation into circuit simulators.

Since the limitations of the standard SPICE Gummel-Poon model (SGPM), especially for design-ing high-speed circuits, have been well-known for many years (cf. examples in [42]), the advanced model HICUM has been developed to address the above mentioned requirements.

1.2 Model features overview

HICUM is a semi-physical compact bipolar transistor model. Semi-physical means that for arbitrary transistor configurations, defined by emitter size as well as number and location of base, emitter and collector fingers (or contacts, respectively), a complete set of model parameters can be calculated from a single set of technology specific electrical and technological data (cf. [44]). For this, the value of each element in the equivalent circuit is related to a function describing the dependence on so-called specific electrical data (such as sheet resistances and capacitances per unit area or length), technological data (such as width and doping of the collector region underneath the emitter), physical data (like mobilities), transistor dimensions (such as design rules), operating point, and temperature. The availability of such a semi-physical compact model is an important precondition for circuit optimization with respect to, e.g., maximum speed and low power consumption as well as for including process variations in the design.

The name HICUM was derived from *HI*gh-*CU*rrent *M*odel, indicating that HICUM initially was developed with special emphasis on modelling the operating region at high current densities which is very important for certain high-speed applications. The first version was described in detail in [31,47,26,32,33] and was verified for digital applications based on a conventional technology. Later, formulas for the calculation of the base resistance were developed [27,34,35] which include three-dimensional effects occurring in short transistors with an emitter length approaching the emitter width. The latter sizes are important for low-power designs. The introduction of self-aligning poly-silicon technologies as well as the extension of the model to high-frequency analog operation led to improvements [29,14] w.r.t. the first version, which were also verified for very fast large-signal digital-type applications [39].

HICUM is based on an extended and Generalized Integral Charge-Control Relation (GICCR) [30,25,32,36]. However, in contrast to the (original) Gummel-Poon model (GPM) [1] as well as the SPICE-GPM (SGPM) [2] and its variants, in HICUM the (G)ICCR concept is applied consistently without inadequate simplifications and additional fitting parameters (such as the Early voltages). Since reliable design and optimization of high-speed circuits requires accurate modeling mainly of the dynamic transistor behavior, quantities like depletion capacitances and the transit time of mobile carriers as well as the associated charges, which determine the dynamic behaviour, are considered as basic quantities of the model. An accurate approximation of these basic quantities as a function of bias yields, thus, not only an accurate description of the small-signal and dynamic large-

signal behaviour but also - via the (G)ICCR [36] - of the d.c. behaviour. This coupling between static and dynamic description leads, moreover, to a reduction of "artificial" model parameters like Early voltages and knee currents. Furthermore, the above mentioned basic quantities can be easily and accurately determined by standard small-signal measurement methods.

The modularity and physics-based approach of HICUM allows the construction of a model hierarchy without additional effort in parameter extraction. Based on HICUM Level2 (HICUM/L2) and its corresponding set of specific electrical parameters, the simplified version HICUM Level0 (HICUM/L0) with the same equivalent circuit as the SGPM as well as an electrically and thermally distributed model, HICUM Level4 [60], can be generated. In contrast to the SGPM though, HICUM/L0 eliminates many problems while maintaining similar overall simplicity. The HICUM/Level0 model is presently being implemented in commercial simulators.

The important physical and electrical effects taken into account by HICUM/L2, which is described in Chapter 2.1, are briefly summarized below:

- high-current effects (incl. quasi-saturation)
- distributed high-frequency model for the external base-collector region
- emitter periphery injection and associated charge storage
- emitter current crowding (through a bias dependent internal base resistance)
- two- and three-dimensional collector current spreading
- parasitic (bias independent) capacitances between base-emitter and base-collector terminal
- vertical non-quasi-static (NQS) effects for transfer current *and* minority charge
- temperature dependence and self-heating
- weak avalanche breakdown at the base-collector junction
- tunneling in the base-emitter junction
- parasitic substrate transistor
- bandgap differences (occurring in HBTs)
- lateral (geometry) scalability

Modelling of these effects is reflected not only in the model equations but also in the topology of the equivalent circuit. Although the above listed effects are taken into account, the standard HICUM/L2 equivalent circuit still corresponds to a one-transistor model (see Fig. 2.1.1/1), which has turned out as sufficiently accurate for the vast majority of circuit applications. HICUM/L2 contains elements for describing the internal transistor (index i), the emitter periphery (index p) and the external transistor regions (index x). The internal transistor is defined by the region under the emitter which is assigned an effective emitter width [24,40] and area, respectively, in order to retain a one-

transistor model with an as simple as possible equivalent circuit topology as well as a sound physical background. In contrast to MOS transistor models, the geometry dependent calculations have been implemented in a separate program (TRADICA, cf. [44]) for various reasons (e.g. [63]).

Due to its semi-physical nature HICUM/L2 possesses geometry scaling capabilities up to high current densities [40]. In order to make use of these scaling capabilities specific parameters have to be determined from measurements, for which instructions have been developed (e.g., [23,26,28,15, 16]. Parameter extraction as well as generation of model parameters for different transistor configurations will be addressed in Chapter 4. Notes on operating point information that need to be available in (commercial) circuit simulators are provided in Chapter 5.

As the experimental results in chapter 6 show, the accuracy and applicability of HICUM has been demonstrated for a variety of different technologies, ranging from a low-speed and relatively high-voltage process to present SiGe production processes, as well as for many different operating modes.

This documentation includes the contents of change notes up to the version specified on the title page. The differences of new model releases will be documented first separately in order to simplify code updates, and will then be incorporated into this documentation.

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